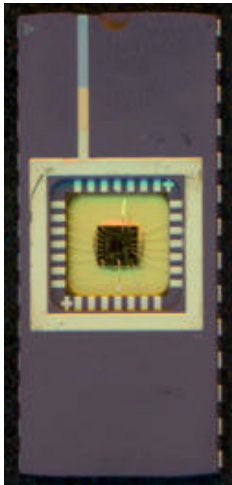
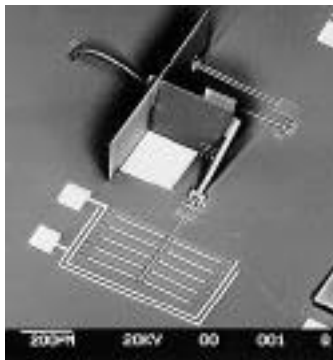


Microelectromechanical Systems



**Dr. Albert P. Pisano
MEMS Program Manager
Electronics Technology Office
Defense Advanced Research Projects
Agency**

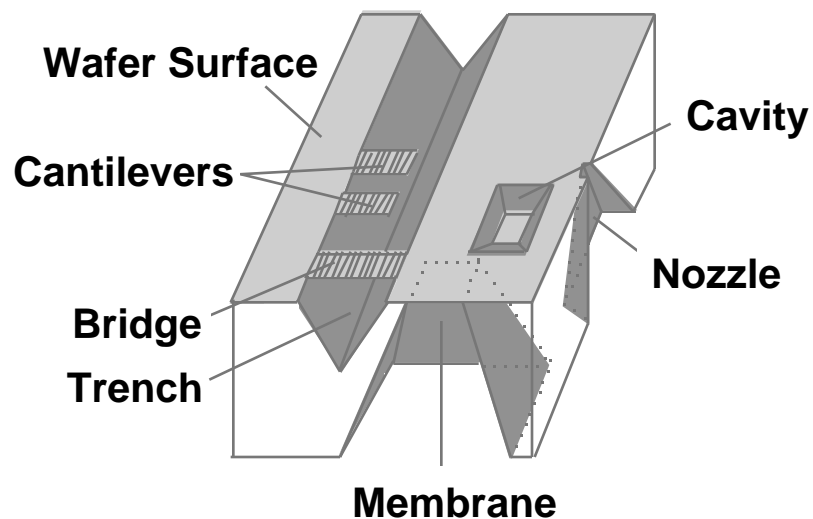


**(703) 696-2278
apisano@darpa.mil
<http://eto.sysplan.com/ETO/MEMS/>**

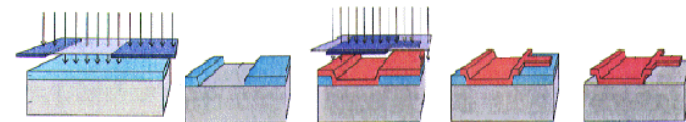
MEMS Description/Fabrication



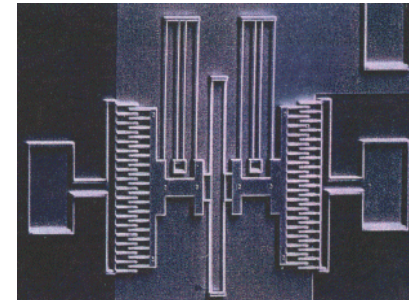
Common MEMS Fabrication Processes



Bulk Micromachining



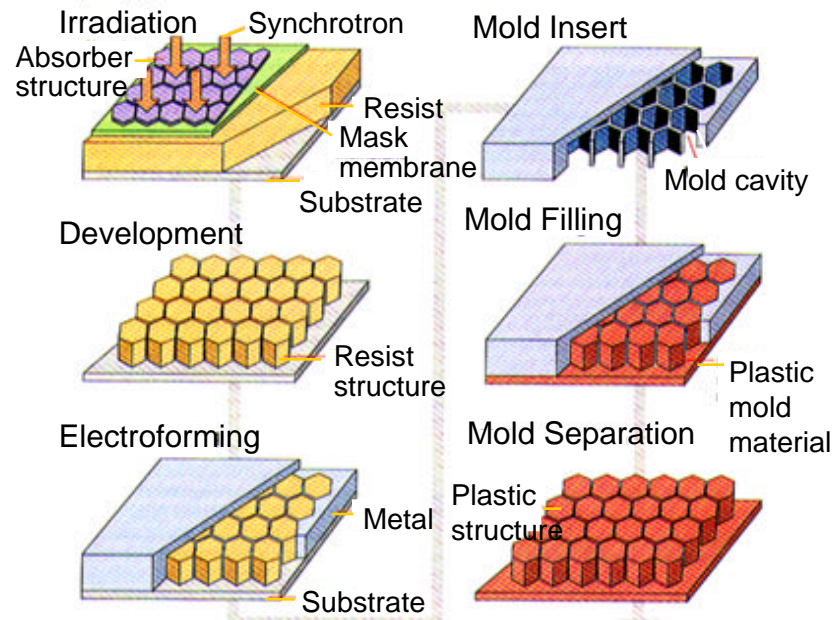
Surface Micromachining



MEMS co-locate sensing, computing, and actuating to change the way we perceive and control the physical world

MEMS Description/Fabrication

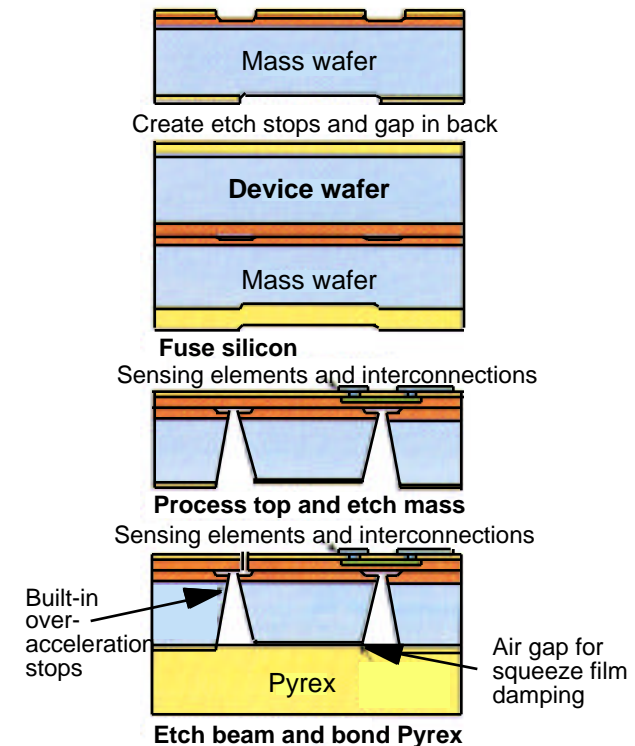
LIGA*, Deep UV



Source: IMM (Mainz Institute for Microtechnology)

*Lithographie, Galvanoformung, Abformung

Wafer-to-Wafer Bonding



MEMS are a new way to make both mechanical and electrical components for microscale flux control

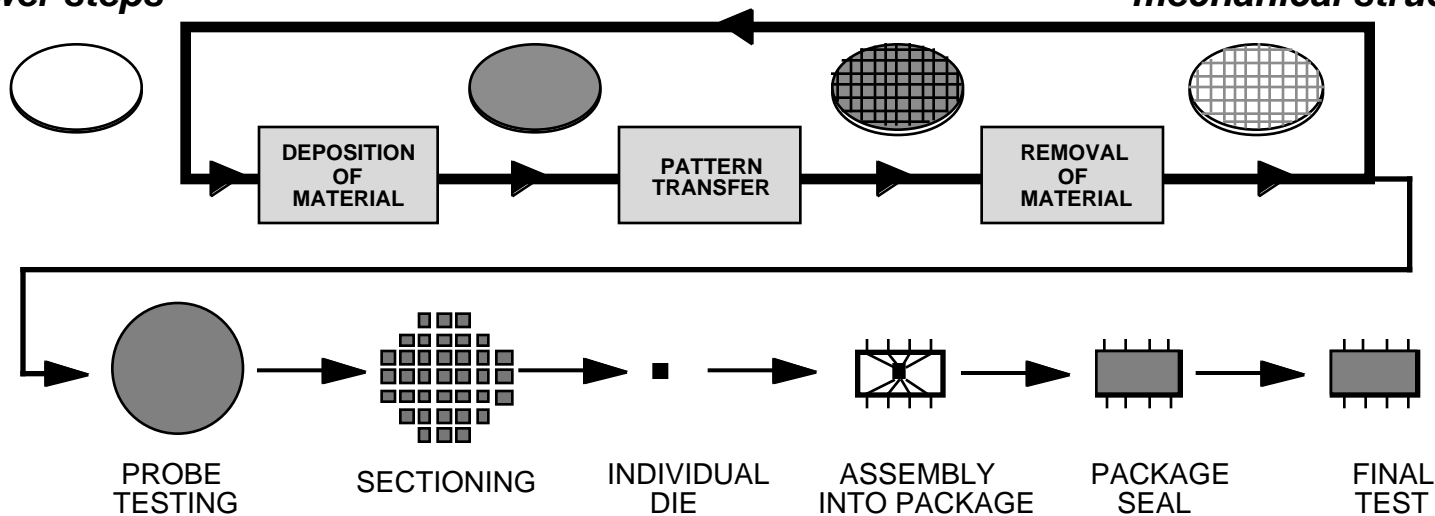
MEMS Builds on Microelectronics Manufacturing



*Thicker films
deeper etches
fewer steps*

Multiple Processing Cycles

*Removal of underlying
materials to release
mechanical structures*



*Special probing, sectioning and handling
procedures to protect released parts*

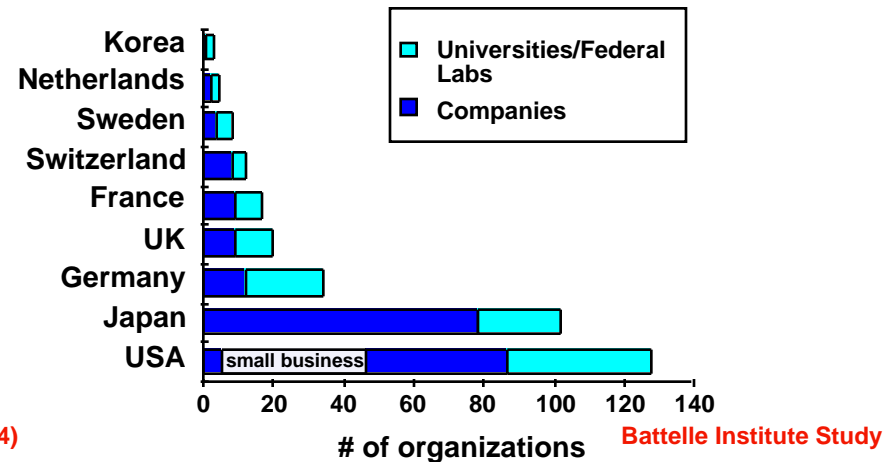
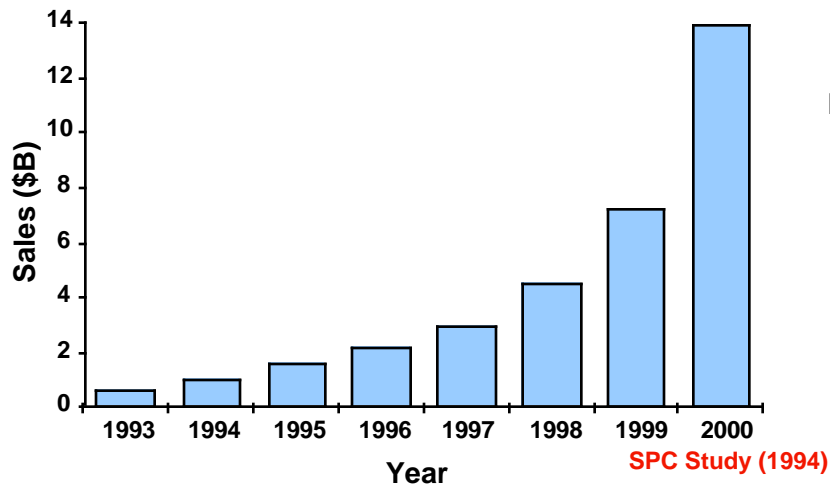
*Encapsulate some parts
of device but expose others*

*Test more than just
electrical functions*

MEMS Market and Industry Structure



Projected Growth of Worldwide MEMS Market



- Not dominated by defense manufacturers
- Populated by diverse industries
 - sensors
 - industrial & residential controls
 - electronic components
 - computer peripherals
 - automotive & aerospace electronics
 - analytical instruments
 - office equipment

Defense Applications of MEMS



▪ **Inertial navigation units on a chip** for munitions guidance and personal navigation

▪ **Electromechanical signal processing** for ultra-small, ultra low-power wireless communication

▪ **Distributed unattended sensors** for asset tracking, environmental monitoring, security surveillance

▪ **Integrated fluidic systems** for miniature analytical instruments, propellant and combustion control

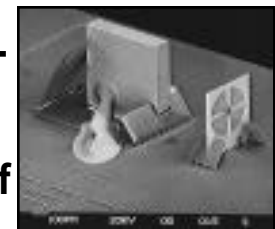
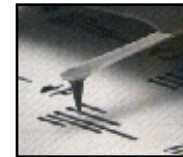
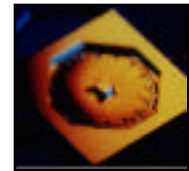
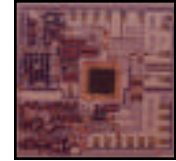
▪ **Weapons safing, arming and fuzing**

▪ **Embedded sensors and actuators** for condition-based maintenance

▪ **Mass data storage devices** for high density, low power

▪ **Integrated micro-optomechanical components** for identify-friend-or-foe systems, displays and fiber-optic switches

6 ▪ **Active, conformable surfaces** for distributed aerodynamic control of aircraft and adaptive optics



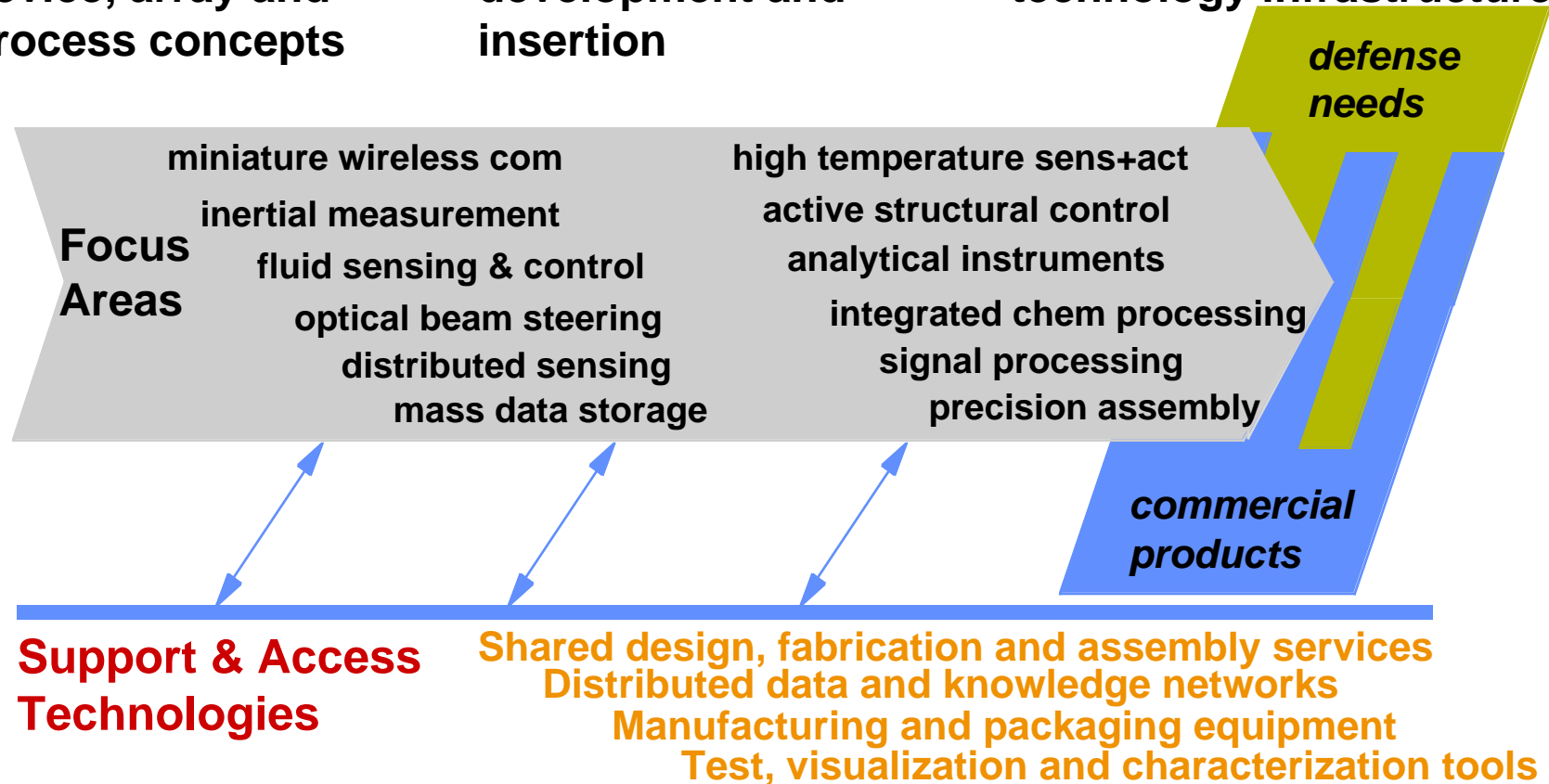
MEMS Program Objectives and Plan



- Realize advanced device, array and process concepts

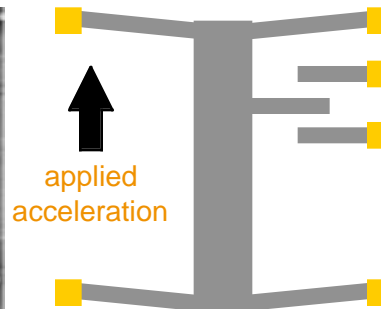
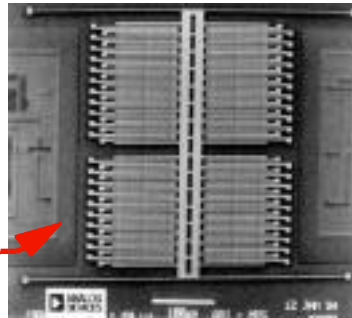
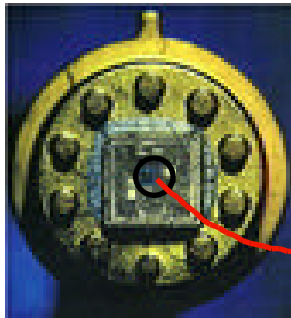
- Accelerate systems development and insertion

- Catalyze a distributed technology infrastructure

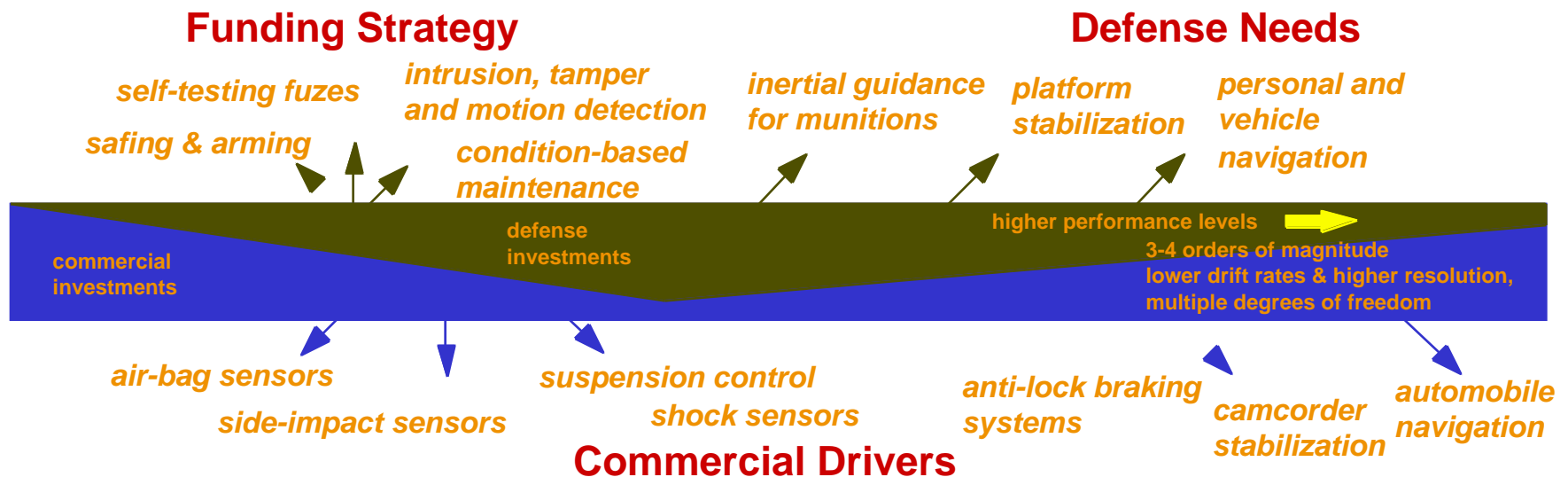


Inertial Instruments on a Chip

ADXL-50



- +/- 50g full scale
- DC to 1 khz
- 200g shock
- 5 volt power supply
- \$10 each in volume
- 200 transistors
- Integrated self-test, signal conditioning
- Manufactured on modified IC line

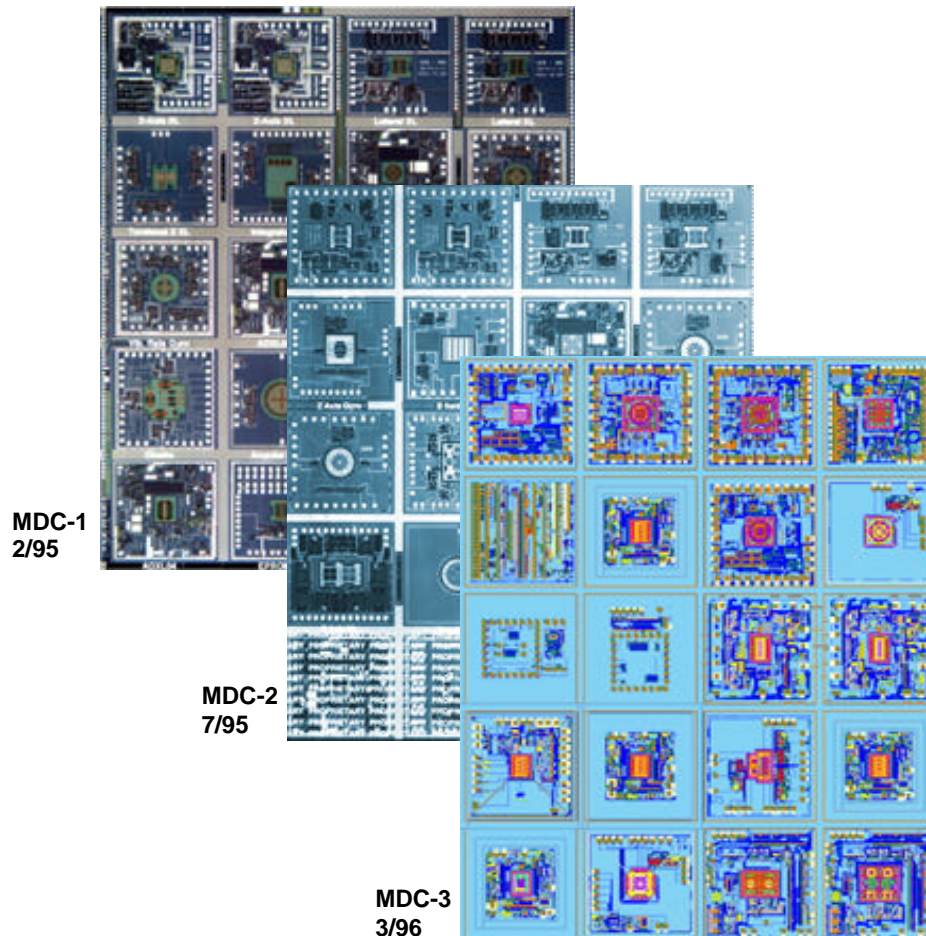


Multiple Device Chips



ETO

MEMS



- z-axis accelerometers
- lateral accelerometers
- angular accelerometers
- integrator structures
- vibrational rate gyros
- high-Q EM filters
- lateral oscillators
- flow sensors
- resonant accelerometers
- EPROMs
- ADXL05
- ADXL50
- ADXL75
- signal processing elements

Analog Devices/UC Berkeley

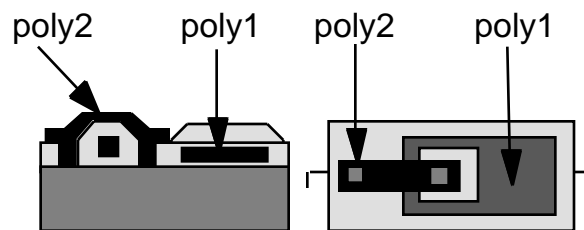
Optical MEMS Components



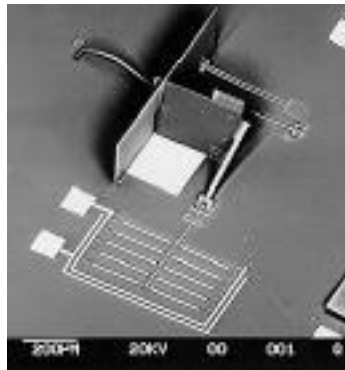
ETO

MEMS

Fabrication sequence

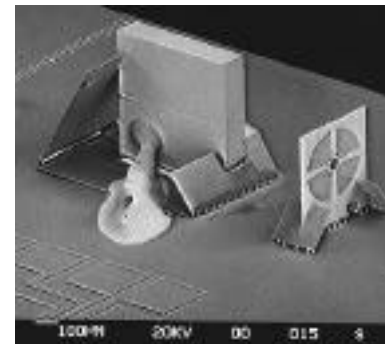
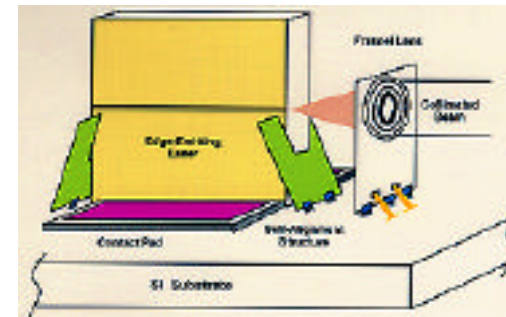


Corner cubes



- Out-of-plane hinged structures fabricated in-plane
- Integrated micro-optomechanical components that are subsequently “assembled”

Integrated optical components



- Corner cube reflectors (low-power, line-of-sight communications and identify-friend-or-foe)
- Optical interconnects and aligners

UCLA

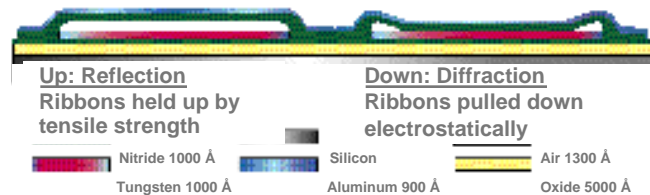
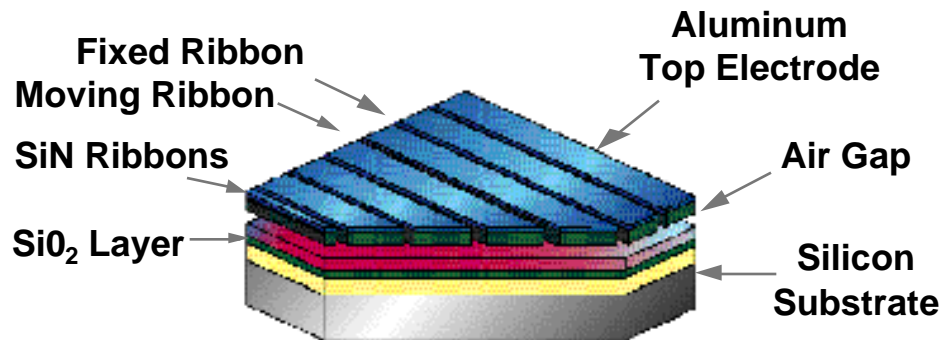
Optomechanical Displays



ETO

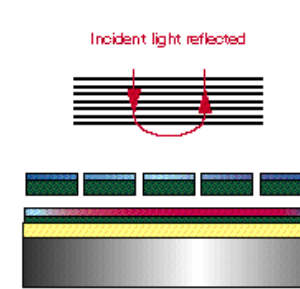
MEMS

Grating Light Valves

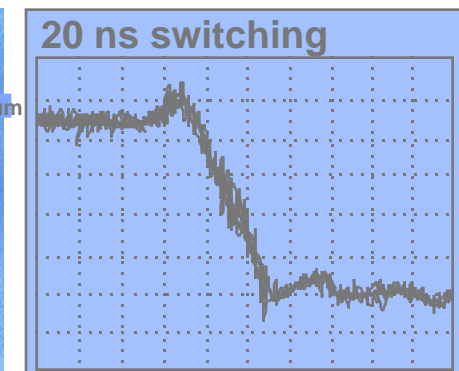
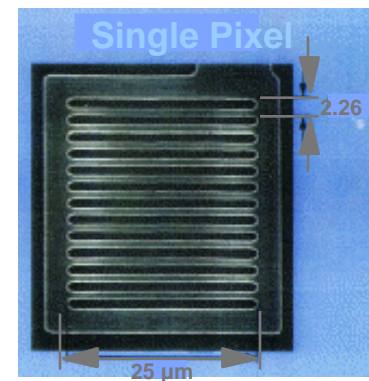
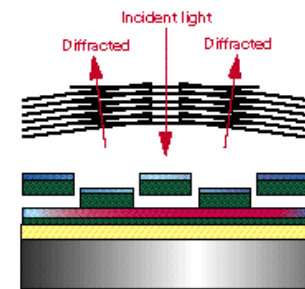


- Silicon surface-micromachined, deformable grating modulator
- No phosphors or liquid crystals
- Low-power, bi-stable switching
- RGB color capability
- 20 nanosecond switching time
- Full motion video
- Digital gray scale

Dark State



Bright State



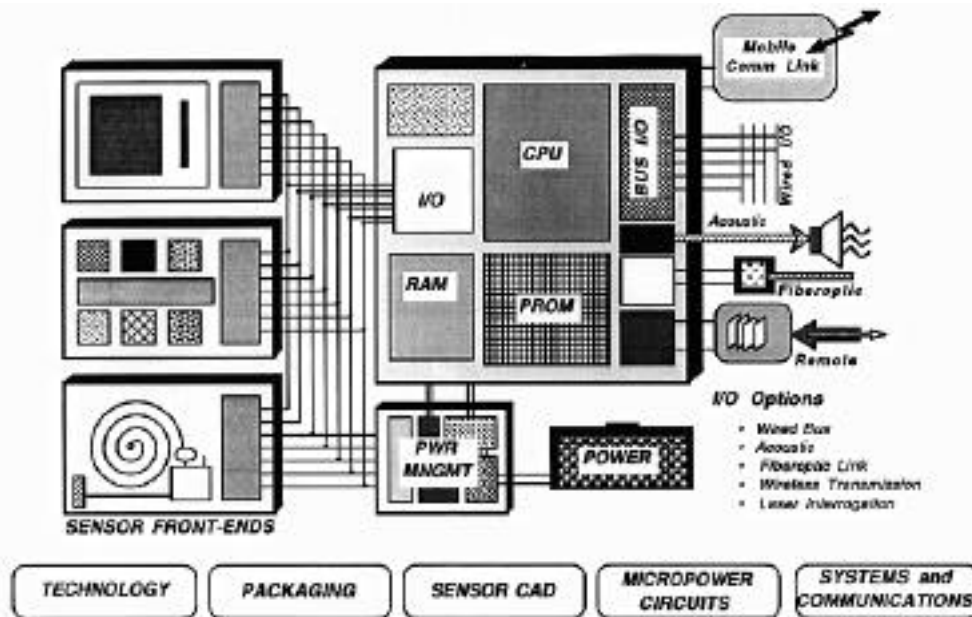
Silicon Light Machines

Environmental Monitoring Sensor Cluster



ETO MEMS

Wristwatch-sized generic sensor cluster -
measurement of temperature, barometric pressure, & vibration



Telemetry Range: 50 ft.
Average Power Dissipation: <500 μ W
Portable Operating Life: 120 days
Barometric Pressure Range (Abs): 550–850 Torr
Ambient Temperature Range: –20 to +60° C
Humidity Measurement Range: 30–90% RH
Acceleration Range: \pm 2g

Specific Applications:

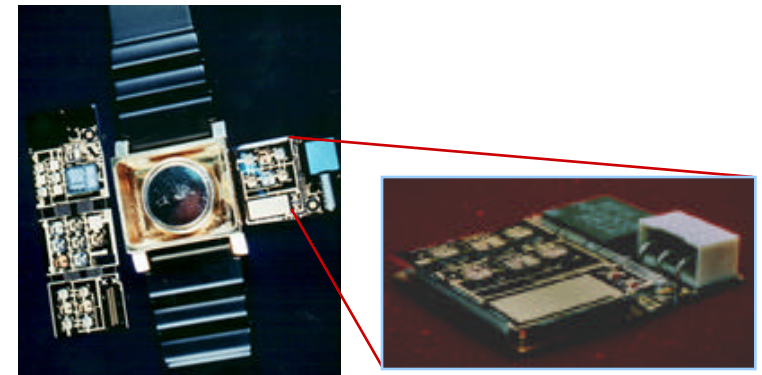
Air Force Phillips Laboratory
Airport Weather Monitoring

Naval Research Laboratory
Unmanned Air Vehicle Applications

Naval Research Laboratory
Ocean Buoy-Mounted
Environmental Sensing

Marine Science Advisor
Environment/Weather Sensors

Department of Transportation
Airport Weather Monitoring

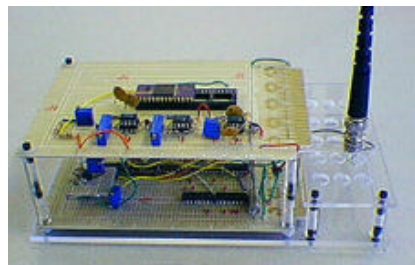


University of Michigan

Low Power Wireless Integrated Microsensors (LWIM)



- Distributed, autonomous, wireless microsensor network with signal processing decision capability
- Single-chip RF transceiver integrated with sensors and integrated RF components
- Low power/low noise analog signal processing based on weak inversion CMOS



LWIM-I node



LWIM-I low power receiver and
base station interface



PC-notebook base station and
LWIM Windows interface

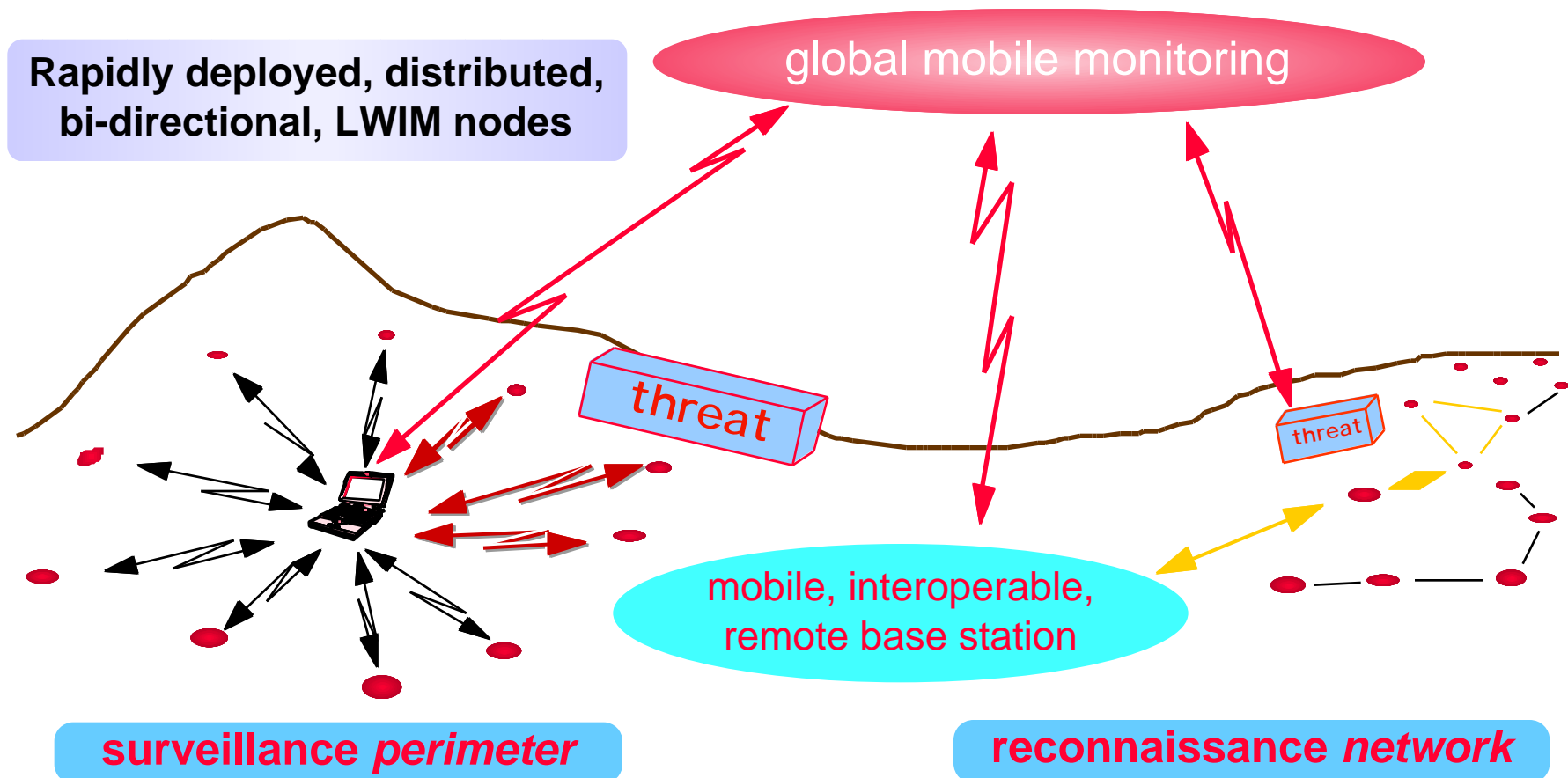
Emerging Applications

battlefield awareness
situational awareness
munitions targeting
condition-based maintenance
environmental monitoring
biomedical monitoring
civil safety and security
commercial manufacturing
transportation

surveillance, perimeter and base security
detection, identification, tracking
munitions impact, target location
vehicle, powerplant, transmission, propulsion
external and internal local and global control
personnel health status monitor
residence, commercial, public structures, urban
precision machining with low cost tools
IVHS, vehicle control

UCLA/Rockwell

LWIM Intelligent Distributed Nodes: Tactical Remote Sensor Systems



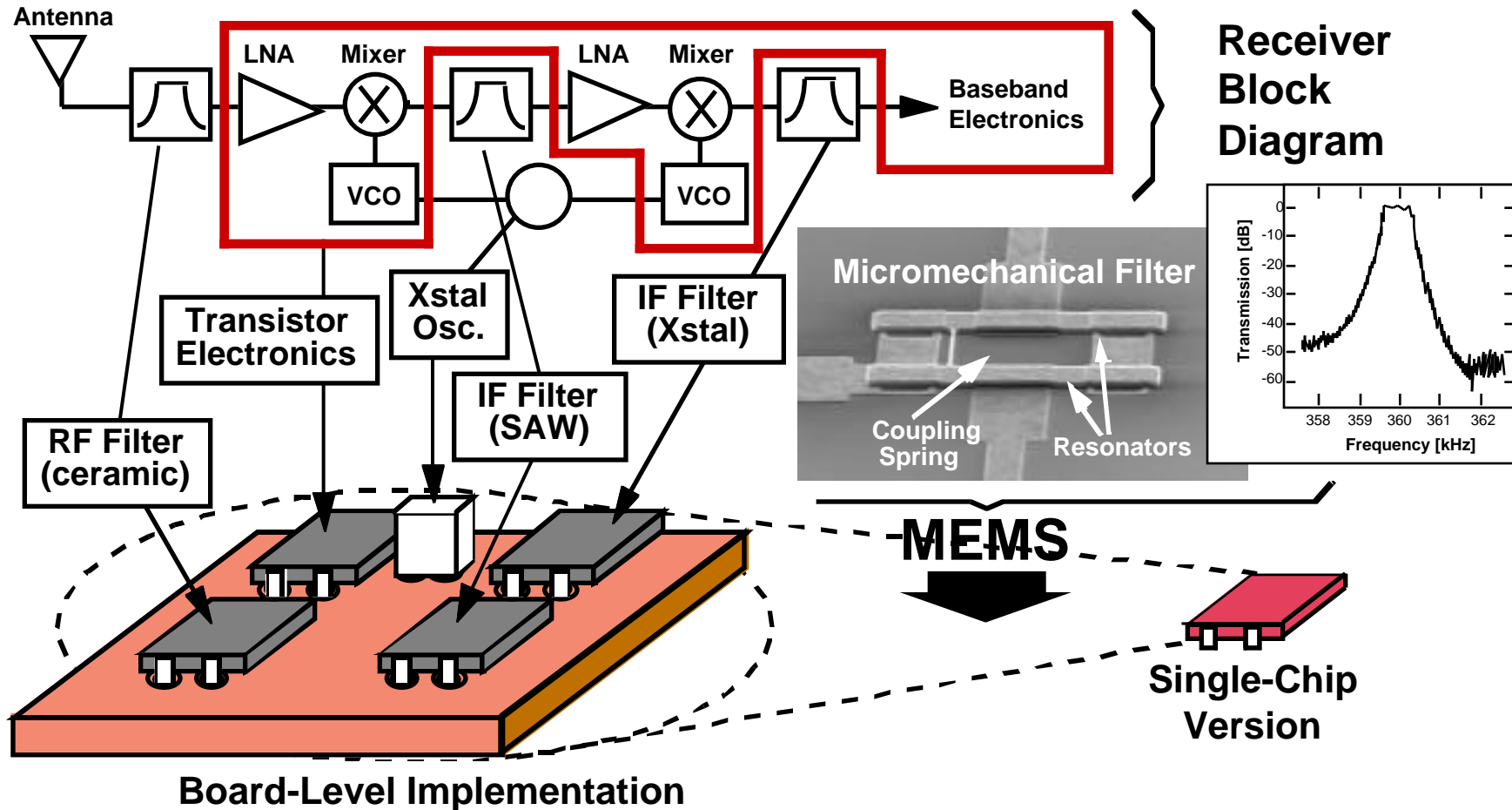
UCLA/Rockwell

Radio-Frequency MEMS



ETO

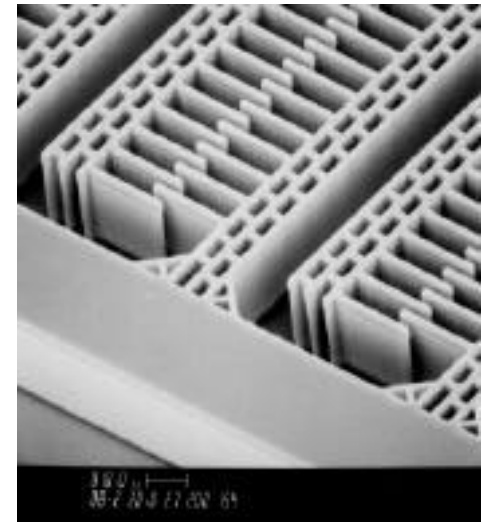
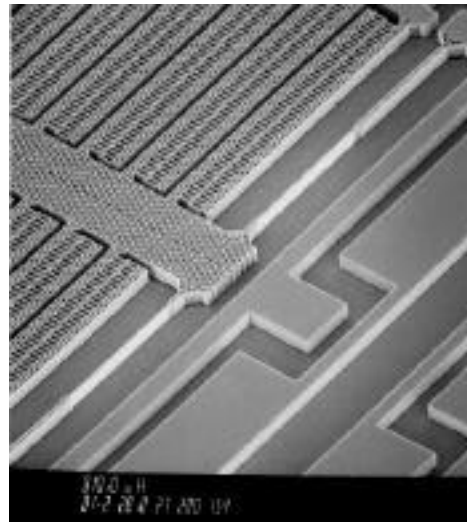
MEMS



Radio Frequency MEMS

- **Technical challenges**
 - Antenna, Frequency Band, Size, Weight, Power
- **MEMS solution**
 - Replace discrete, off-chip components (switch, varactor, inductor)
 - Replace entire electrical circuits with electromechanical signal processing (filters, oscillators, modulators, de-modulators)

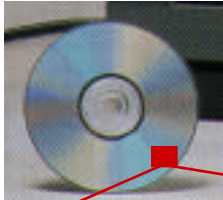
- **Single Crystal Silicon**
- **Superior Mechanical Properties**
- **High Aspect Ratio (20 to 1)**
- **Higher Linearity**
- **Large Tuning Ratio (> 6.5 to 1)**



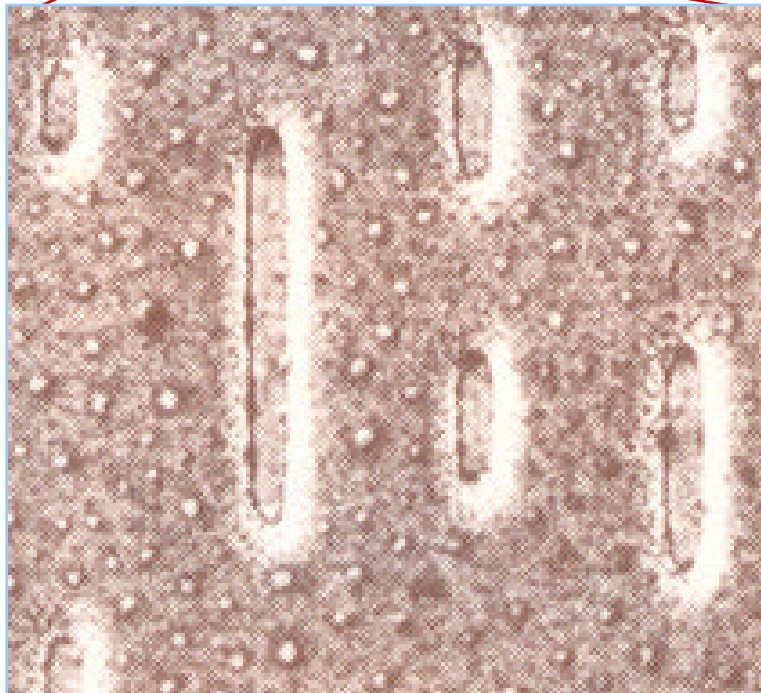
SEM micrographs of the MEMS tunable capacitor

Rockwell

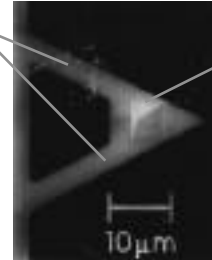
Mass Data Storage



Compact Disk
~620 MBytes in ~23 in²



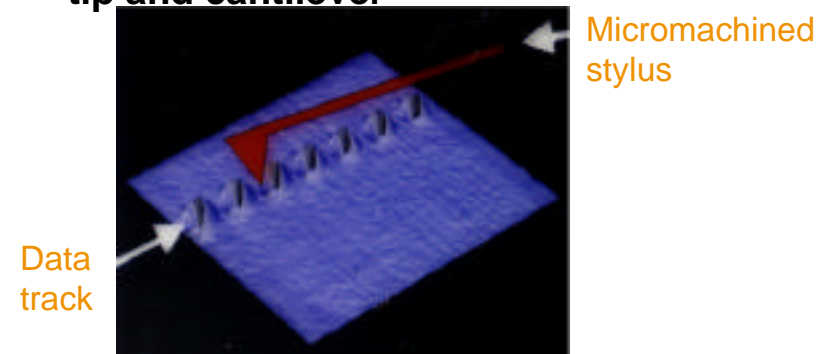
Cantilever



Writing tip

**Atomic Resolution
Data Storage**

**Micromachined silicon read/write
tip and cantilever**



Data track

Micromachined stylus

Data pits read using AFM techniques



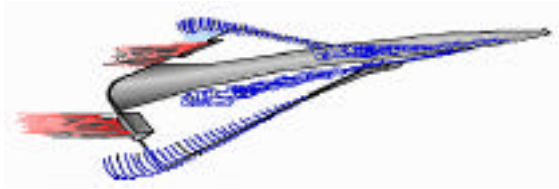
Written data pits

~50 GBytes in same area (8x)

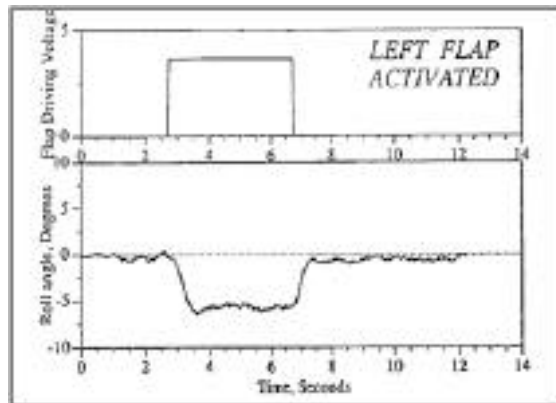
IBM

Active Conformable Surfaces

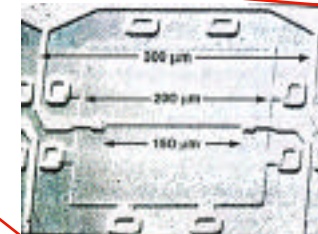
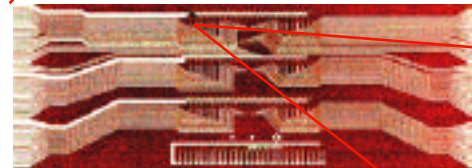
Advanced Aerodynamic Control



Distributed MEMS sensors & actuators control separation of leading-edge vortices



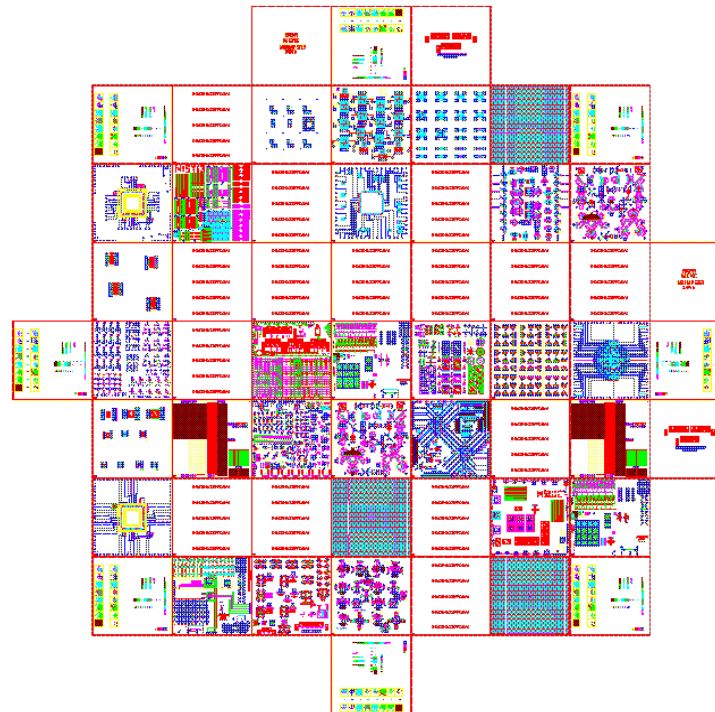
Wind tunnel roll measurements



- Aircraft and projectiles with no large, discrete control systems
- Higher maneuverability, greater lift, reduced drag

UCLA/CalTech

MCNC-DARPA Multiproject Chip Run



MUMPs13

MCNC-DARPA MEMS Multiproject Run

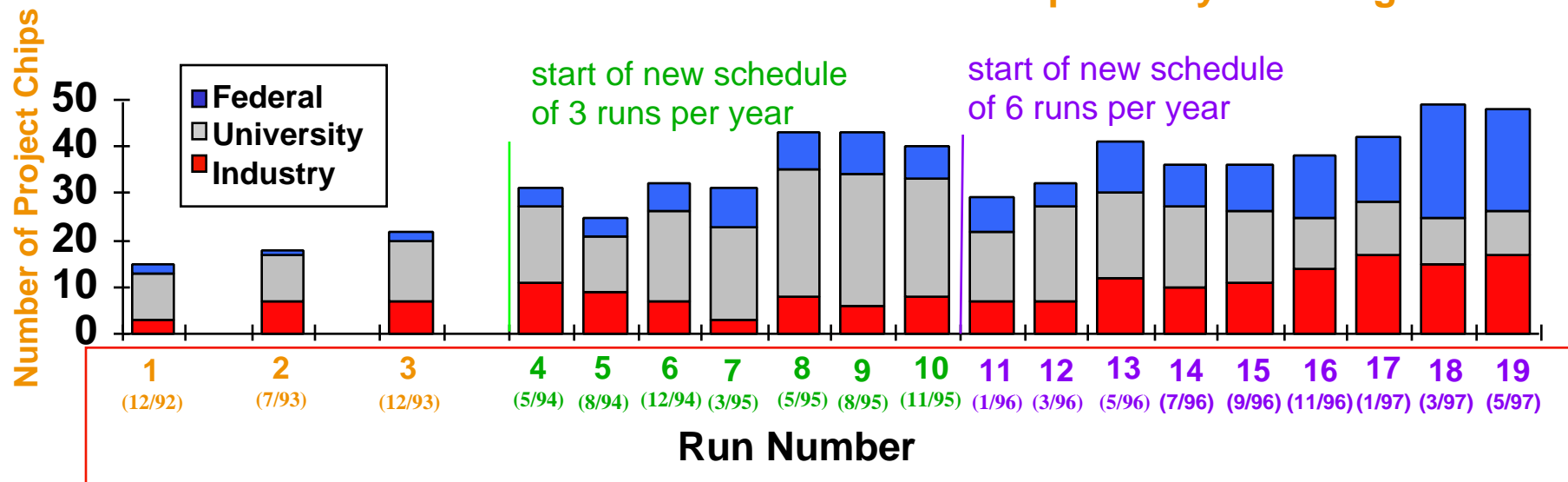
MCNC

Multi-User MEMS Projects (MUMPs)



Accelerating innovation and commercialization by providing MEMS fabrication technologies to multiple, remote users

\$850 + design → **MCNC (10 weeks later)** → **one dozen 1 cm x 1 cm MEMS chips with your design**



30% of users are getting their first access to MEMS technology through MUMPs

~ 550 projects, 1000 users in total

MCNC